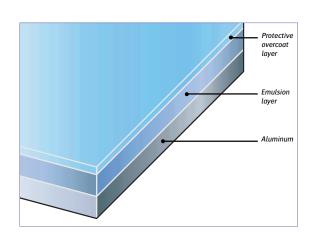




High Performance Violet Photopolymer Plate Technology

Key Features

- Proven and stable technology- descendant of first high speed metal CTP plate
- Durable substrate
- Wide operating latitude
- Optimal press performance
- Highly durable
- Long laser life
- Optimized for the PlateStream® Violet 2-up metal platesetter and processor



Specifications

Plate type	Negative-w	rorking l	high-enood	lacor plato
Plate type	Negative-w	orking, i	nign-speed	laser blate

Coating Photopolymer

Gauges 0.008" (0.20 mm), 0.012" (0.30 mm)

Surface Electrochemically grained and anodized

Sizes Standard sheetfed and webfed forms

Sensitivity 405nm violet diode.

Exposure energy Stouffer 21 step wedge: step 3, solid 5

ghost;

UGRA wedge: step 2 solid 4 ghost

Resolution* 2% - 98% at up to 200 lpi

Processor speed Up to 2m/min.

Working conditions Operating temp 23 ±2 °C,

50% ±10% relative humidity

Storage conditions <30 °C. Do not expose to 50°C

temperatures for not more than

24 hours.

Recommended 30% to 70%

relative humidity

Run length** Up to 250,000 unbaked, 1,000,000

baked

^{**} run length dependent on press conditions



^{*} plate resolution dependent on platesetter/exposure equipment and conditions